

Supplementary Information

A Facile and Novel Design of Multifunctional Electronic Skin Based on Polydimethylsiloxane with Micropillars for Signal Monitoring

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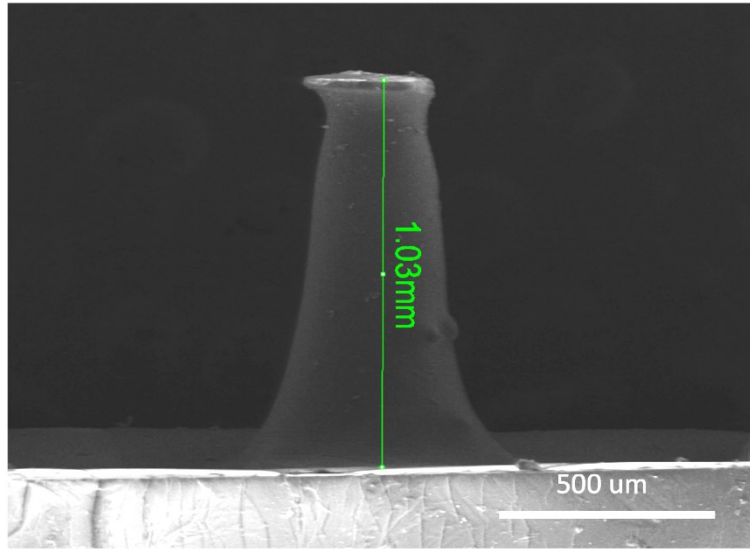


Fig. S1 The cross-sectional SEM image of a micropillar.

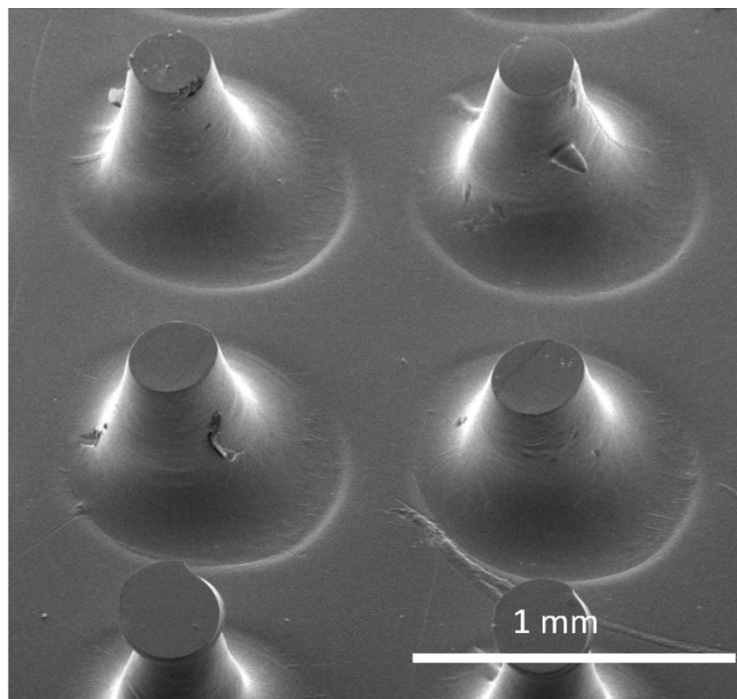


Fig. S2 The 5-angle top-view SEM image of the micropillars.

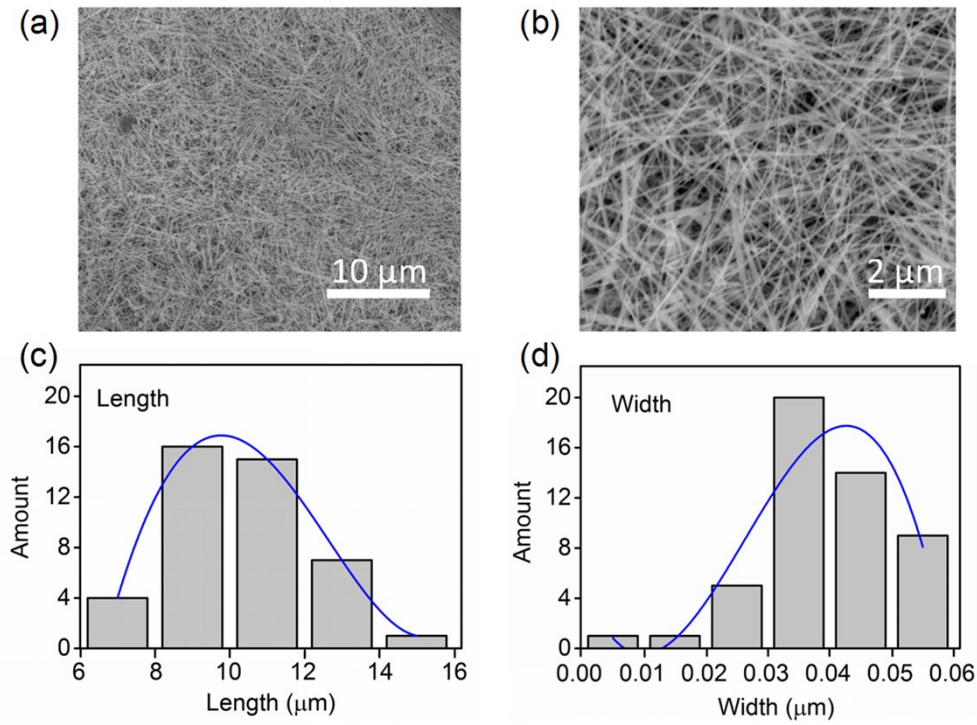


Fig. S3 SEM images of AgNWs with larger scales as (a) scale bar 10 μm and (b) scale bar 2 μm. The nonlinear fitting distribution curves of (c) length and (d) width values of AgNWs.

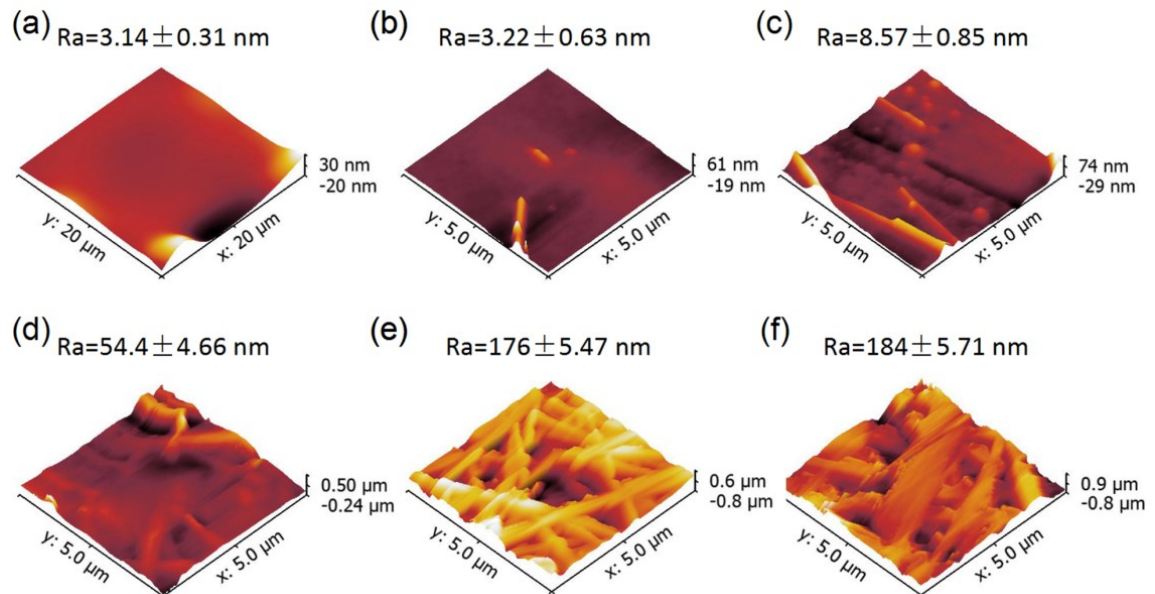


Fig. S4 AFM images of (a) plain PDMS and PDMS coated with (b) 1 layer, (c) 2 layers, (d) 3 layers, (e) 4 layers, and (f) 5 layers of AgNWs.

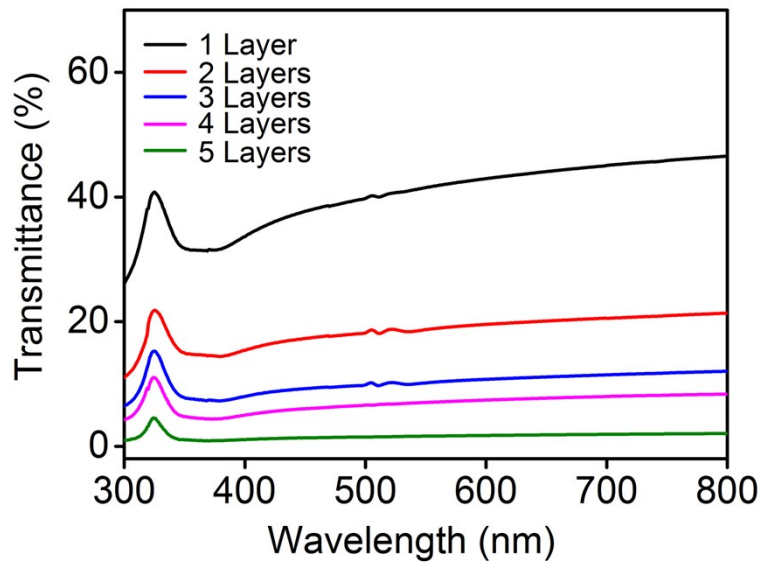


Fig. S5 The optical transmittances of substrates with various layers of AgNWs.

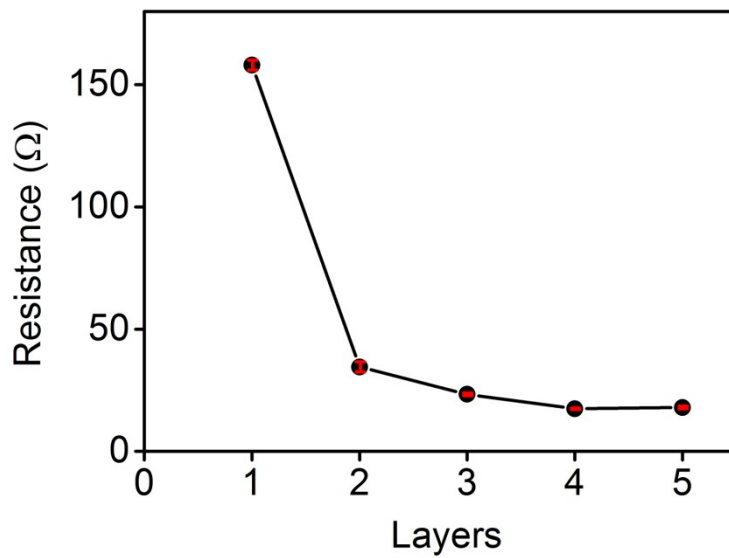


Fig. S6 The resistances of substrates with various layers of AgNWs.

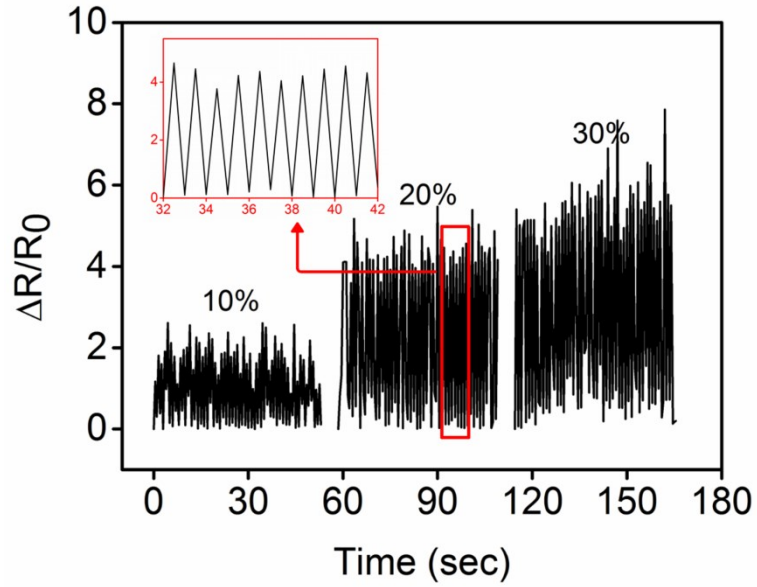


Fig. S7 The normalized electrical resistance changes ($\Delta R/R_0$) of the e-skin under cyclic mechanical stretching and releasing at the rate of 1 Hz with strain as 10%, 20%, and 30%, respectively.

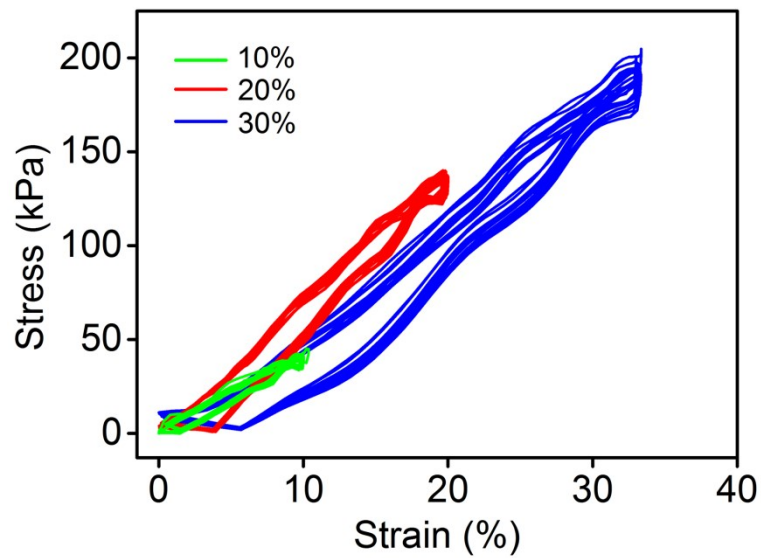


Fig. S8 The stress-strain curves of e-skin with different mechanical strains.

Table S1 The response ranges and sensitivity values of e-skins.

Elements	Parameter	Response range	Sensitivity	R²
Bottom radii	100 μm	0-100%	0.136	0.997
	150 μm	0-100%	0.09	0.978
	200 μm	0-100%	0.066	0.932
	250 μm	0-100%	0.043	0.955
	300 μm	0-130%	0.0159	0.99
Spacing	600 μm	0-90%	0.084	0.961
	800 μm	0-100%	0.085	0.991
	1000 μm	0-100%	0.136	0.997
	1200 μm	0-100%	0.113	0.998
	1400 μm	0-100%	0.092	0.993
Geometric arrays	hexagon	0-100%	0.147	0.999
	square	0-100%	0.136	0.997
	central square	0-100%	0.105	0.995
	triangle	0-100%	0.088	0.97